

ABSTRACT OF THE DISCLOSURE

A substrate-processing system has several processing units, a loading/unloading section for transferring wafers

5 to be processed to each unit and taking out processed wafers from each unit and a sub-arm mechanism for receiving/transferring the substrates from/to the loading/unloading section and transferring the substrates one by one to each unit. The processing units and the sub-arm mechanism are

10 controlled by a controller so that each unit processes the substrates one by one in accordance with a one-cycle time that is the maximum period among periods t_1/m to t_n/m obtained by dividing periods t_1 to t_n by the number "m" of identical units of each processing unit. The controller sets a

15 pre-waiting time (before processing) for each processing unit.